## AMENDMENTS TO THE SPECIFICATION:

Please replace the paragraph beginning at page 8, line 10, with the following amended paragraph:

The average grain diameter of the abrasive grains is not particularly limited, but it is preferably 1 µm to 60 µm, more preferably 5 µm to 20 µm. The average grain diameter of the abrasive grains of less than 1 µm is not practical because the cutting speed becomes remarkably low. The average grain diameter of the abrasive grains of more than 60 µm [[·m]] is not preferable because the surface roughness of the wafer surface becomes large after cutting, which degrades the quality of the wafer.